계산전자공학 Assignment #13 주원빈 20182018

Problem #1

Case 1: Long structure (600 nm)

100 nm: Highly doped (5x10¹⁷ cm⁻³)

400 nm: Lowly doped (2x10¹⁵ cm⁻³)

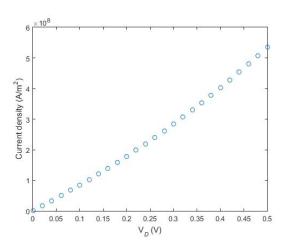
100 nm: Highly doped (5x10¹⁷ cm⁻³)

Case 2: Short structure (120 nm)

40 nm: Highly doped (5x10¹⁹ cm⁻³)

40 nm: Lowly doped (2x10¹⁷ cm⁻³)

40 nm: Highly doped (5x10¹⁹ cm⁻³)



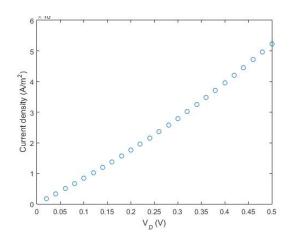


Figure 1 Current density of doped silicon. (1) Case 1: Long structure (2) Case 2: Short structure.

C = 5 pF

 $R = 2 M\Omega$

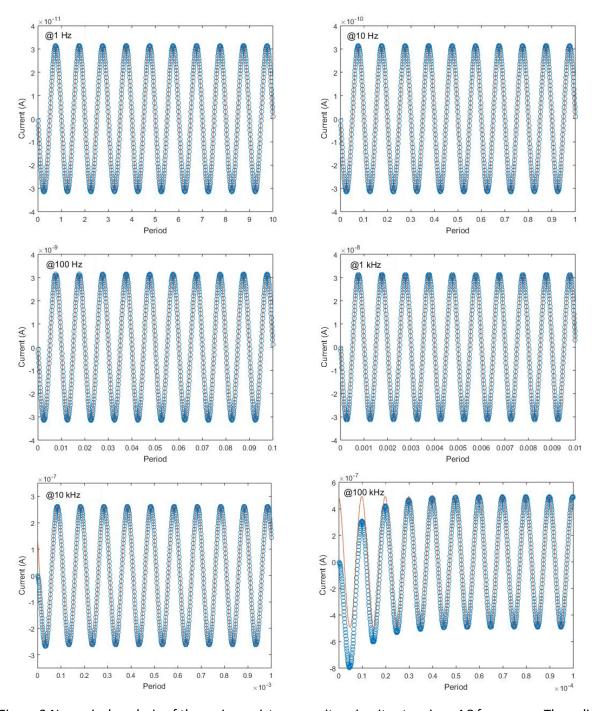


Figure 2 Numerical analysis of the series resistor-capacitor circuits at various AC frequency. The solid lines are exact solution and blue symbols are numerical results.